

Applicant:

Paton et al.

Title:

**OFFSET SPACER SMOS** 

PROCESS FOR FORMING N-

TYPE TRANSISTORS

Appl. No.:

10/619,877

Filing Date: 07/15/2003

Examiner:

Christy L. Novacek

Art Unit:

2822

CERTIFICATE OF EXPRESS MAILING I hereby certify that this correspondence is being deposited with the United States Postal Service's "Express Mail Post Office To Addressee" service under 37 C.F.R. § 1.10 on the date indicated below and is addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450. EV 505576442 US 11/22/04 (Express Mail Label Number) (Date of Deposit) Roberta A. Cooper (Printed Name) (Signature)

## DECLARATION UNDER 37 C.F.R. § 1.131

Commissioner for Patents PO Box 1450 Alexandria, Virginia 22313-1450

Sir:

We, Eric N. Paton, Haihong Wang, and Qi Xiang, state and declare that:

- 1. Each of us is an inventor of at least one of Claims 1-20 currently pending in U.S. Patent Application No. 10/619,877 (hereinafter "the '877 application").
- 2. We understand that in an Office Action dated September 23, 2004, Claims 1-4, 7-10, and 17-20 were rejected as being unpatentable based in part on the use of U.S. Patent No. 6,762,085 to Zheng et al., entitled "METHOD OF FORMING A HIGH PERFORMANCE AND LOW COST CMOS DEVICE" (hereinafter "Zheng et al.").
- 3. We understand based on the information provided on the front page of Zheng et al. that Zheng et al. has a filing date of October 1, 2002.
- 4. At least by June 28, 2002, we conceived in the United States the ideas set forth in Claims 1-20 of the '877 application. Such conception is evidenced by the attached invention disclosure form pertaining to the subject matter of the present application, and which is dated June 28, 2002.
- 5. Based on the conception of the ideas set forth in Claims 1-20 at least by June 28, 2002, the subject matter recited in Claims 1-20 was invented by us prior to the October 1, 2002 filing date of Zheng et al.

6. We hereby declare that all statements made herein of our own knowledge are true and that all statements made on information and belief are true, and further that these statements are made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the patent application or any patent issuing therefrom.

| Date: | 11/18/04   | By:Eric N. Paton |
|-------|------------|------------------|
| Date: | 11/18/2004 | By: Haihong Wang |

Date: 11/17/04 By: X Qi Xiang

| FRIORITY CODE  |
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| Friday, June 28, 2002 SMOS Patent Harvesting Session, Group 4:  A B X C D  |
| Technical Leader: Oi Xiang   |
| AMD INVENTION DISCLOSURE TLD ID# 10970 Rec'd date  |
| California & Asia: x42110, return to MS68; Texas: x55964 return to MS562; Dresden & Europe: x83401 Silke Kretzschmar at MS E21-PP.   |
| This invention applies to: Project: Product: Process: Technology: Other:   |
| IMPORTANT Please identify any potential use:   |
| TIMI ORIANT Trease are may any posterior asset   |
| List 2 to 5 key search words related to the invention:   |
| Working title of invention: Offset spacer for NMOS As Extension implant to compensate for As enhanced diffusion  |
| implant to compensate for As enhanced diffusion  |
|  |
| Inventor's signature: Eric Paton date: 6/28/02   |
| inventor's printed full name:Citizenship   |
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| Co Inventorio simplemento Hai Hana INIANA  |
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| Co-Inventor's printed full name: Citizenship:  |
| Employee #: Extension: Mail stop: Home telephone:( )   |
| AMD email address: AMD office FAX:( )  |
| Division: Directorate: Dept #: Dept : Manager:   |
| Residence address:   |
| Post Office address:   |
| State total number of inventors here: If there are more than four inventors, insert duplicate page 1.  |
| HARVESTING LAW FIRM ATTORNEYS: FOLEY & LARDNER   |
|  |
| Joe Ziebert, Ron Coslick Witness 1 initial: Witness 2 initial:   |
|  |
| IDF Session 4 Revised on 10/29/01. AMDI CONFIDENTIAL Aftorney-Client Privileged Information Page 1   |

Patent Harvesting Breakout Session, Group 4: SMOS Friday, June 28, 2002 Technical Leader: Qi Xiang

Participant Addresses (Please verify all information and fill in any blank areas)

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| Friday, June 28, 2002<br>SMOS Patent Harvesting Session, Group 4:<br>Technical Leader: Qi Xiang<br>AMD INVENTION DISCLO | SURE TL                                      | NOV 2.2                                    |                                      | AB<br>CD                                       |
| California & Asia: x42110, return to MS68;  | Texas: x55964 return to                      | MS562; Dresde                              | en & Europe: x83401 Si               | lke Kretzschmar at MS E21-PP.                  |
| Identify known relevant art (patents, pu  | blications, other in                         | formation):                                |                                      |  |
| Offset Spacer   | is used                                      | FOR  | Boron 1                              | <u> </u>                                       |
| current Si  | devices                                      | without                                    |                                      |  |
| invention to.   | Boron wit<br>Arsenic                         | h . ве                                     | applied in                           | fk:  |
| State the problem solved by the invention   |  |  |                                      | ral diffusion                                  |
| of Acres 403  | - 102 7N                                     | c entre edo                                | nced later                           | Much overlap                                   |
| of Arsenic und  | rain and                                     | the che                                    | ennel wi                             | 1 result in                                    |
| short chandel effec   | 4.   |  | <u> </u>                             |  |
| Brief description and sketch of the inve<br>pages, reports and drawings that are he                                     | ntion   please attac<br>elpfulfin describing | c <b>h</b> copies of do<br>g / understandi | ocuments like AM<br>ng the invention | ID patent notebook<br>):                       |
| Surpressed 1  | Boron di He                                  | W100 L                                     | ill preve                            | nt Sufficient                                  |
| overlap of the  | gate and                                     | fource                                     | /dchia                               | resulting                                      |
| in too low of   | a dene                                       | carren                                     |                                      | <del>11)</del> ~                               |
| 1 Pros)<br>Beron  | NMOS)  |  |                                      |  |
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| Patent notebook #Pa   | age numbers                                  |  | Numb                                 | er of drawings                                 |
| TIADADOUBLOT  | A W. EIDXALATTO                              | DNEVC. FOL                                 | EV & I ADDNE                         | D 1  |
| HARVESTINGL   | AW FIRM/ATTOI<br>Joe Ziebert, Ro             |  | CI & LAKUNE                          | N.   |
| Witness 1 initial:  | Witness 2 initial: _                         |  |                                      |  |
| IDF Session 4 Revised on 10/29/01. AMDIT CON  |  |  |                                      | Page 2   |
| IDIT Session 4 Revised on 10/29/01.   | THE WILLIAM MICHIGAN                         | wy-Chem Filvine                            | Pog'uričinanou.                      |  |

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| Friday, June 28, 2002  |  |             | NOV 2 2 2004                                   |                  | ·                       | AB                                  |  |  |
| SMOS Patent Harves   |  | 4: \        |  |                  | •                       | CD                                  |  |  |
| Technical Leader: Qi   |  |             | PADEMARY .                                     |                  |                         |                                     |  |  |
| AMD INVEN  |  |             |  |                  | : .                     | Rec'd date                          |  |  |
| California & Asia: x4  | 12110, return to MS68;   | Texas       | x55964 return to MSS                           | 562; Dresden &   | Europe: x83             | 401 Silke Kretzschmar at MS E21-PP. |  |  |
| A.1  |  |             |  |                  |                         |                                     |  |  |
| Advantages (check  |  | <u> </u>    |  |                  |                         |                                     |  |  |
| simplifies man   |  |             | proves accuracy                                |                  |                         | ces component parts                 |  |  |
|  | manufacturing  |             | proves reliability                             |                  |                         | oves signal to noise ratio          |  |  |
| improves dens  |  | im          | improves efficiency provides new functionality |                  |                         |                                     |  |  |
| increases operating speedincreases operating rangeother, explain below |  |             |  |                  |                         |                                     |  |  |
| Discussion of advance (emphasize technical)                            | al <u>advance in the c</u>   | art as m    | easured against l                              | known art):      | the second              | procedure  and Boron                |  |  |
| diffusel   | futer t  |             | Acienic  |                  |                         | vices.                              |  |  |
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| Does plan exist to p  Was invention joint f yes, Company na            | of first drawing(s)  al disclosure of in  bublish, disclose or  ly developed with  me_ | r sell?     | , place, date, circ                            | cumstances of    | ere and where and where | No , Yes ,                          |  |  |
| have read and un   |  |             |  |                  |                         |                                     |  |  |
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| Name(s) of attorney  | (s) preferred by in  | ventor(s    | s) to prepare pate                             | ent application  | , if know               | n:<br>                              |  |  |
|  | AMDTA  | N Ininacaja | THE A T. A 27 PAGE                             | orith, puters    | TLC                     | Decay 2                             |  |  |
| OF Session 4 Revised on 10/29/01.                                      | AMULICO  | MELLINE     | VIIAL Attorney-                                | Chent Privileged | iniormatio              | n Page 3                            |  |  |